

L Number	Hits	Search Text	DB	Time stamp
1	835	(((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/17 10:56
2	497	(((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT ((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/17 10:57

3	318	(((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) or (((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/17 10:57
4	1332	((((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) or (((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/17 10:57

5	1014	<p>((((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) or (((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)))) not (((((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))) or (((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))))</p>	<p>USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB</p>	2004/06/17 11:29
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6	1282	(438/3).CCLS.	USPAT; US-PGPUB	2004/06/17 11:30
7	1057	(438/240).CCLS.	USPAT; US-PGPUB	2004/06/17 11:30
9	1461	((438/240).CCLS.) or (((438/250) or (438/393)).CCLS.)	USPAT; US-PGPUB	2004/06/17 11:31
8	526	((438/250) or (438/393)).CCLS.	USPAT; US-PGPUB	2004/06/17 14:15
-	41690	ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:35
-	1193	ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:36
-	3529	((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:39
-	4819	((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:40
-	7012	((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:40
-	168228	(bottom or lower) adj (electrode\$1 or plate\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:41
-	154461	(top or upper) adj (electrode\$1 or plate\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:41
-	2316	(((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:43
-	2280	(((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:44

-	277894	CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:45
-	277894	CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:46
-	834	(((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4) capacitor or capacitors	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/17 10:55
-	576275	capacitor or capacitors	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:51
-	98486	DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:52
-	643620	(capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:52
-	13767	((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:52
-	2447	((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:53
-	1325	((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 09:54

-	496	(((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/17 10:56
-	1629	((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 10:14
-	186	((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 10:15
-	132	((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 10:15

-	318	<p>(((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))) or (((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))))</p>	<p>USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB</p>	2004/06/17 10:57
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-	364	<p>((((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))) NOT (((((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))) or (((bottom or lower) adj (electrode\$1 or plate\$1)) with (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and (((((((((capacitor or capacitors) or (DRAM\$1 or (dynamic adj random adj access adj memor\$4) or dynamic-random-access-memor\$4)) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4)) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) NOT (((((((((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj ((random adj access adj memor\$4) or RAM\$1)) or FeRAM\$1 or Fe-RAM\$1) or (((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)) or Fe) adj (capacitor or capacitors))) and ((bottom or lower) adj (electrode\$1 or plate\$1)) and ((top or upper) adj (electrode\$1 or plate\$1))) and ((ferroelectric\$3 or ferro-electric\$3 or (ferro adj electric\$3)) or (ferrodielectric\$1 or ferro-dielectric\$1 or (ferro adj dielectric\$1)))) and (CMP or "CMP" or (chemical adj mechanical adj polish\$4) or polish\$4 or planariz\$8 or chemical-mechanical-polish\$4))))))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/16 10:18
-	1278	(438/3).CCLS.	USPAT; US-PGPUB	2004/06/16 17:14
-	1055	(438/240).CCLS.	USPAT; US-PGPUB	2004/06/16 17:15